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Spin-dependent tunneling spectroscopy in MgO-based double-barrier magnetic tunnel junctions

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We investigated the dynamic conductance and inelastic electron tunneling spectroscopy in MgO-based double barrier magnetic tunnel junctions with CoFeB/CoFeB/Cu/CoFeB hybrid free layers. The tunneling is coherent through the MgO (001) barriers but nonresonant, and the highest tunneling magnetoresistance reaches 260% at 2 K. Based on the detailed discussion of the tunneling mechanisms, the double-barrier junctions investigated here can be considered as two single-barrier junctions in series.

I. INTRODUCTION

Tunneling magnetoresistance (TMR) effect in MgO-based single-barrier magnetic tunnel junctions (SMTJs) has been widely studied due to its great potential applications in magnetic random access memory (MRAM) and field sensors. However, the TMR ratio in SMTJs falls off quickly with increasing bias voltage, which limits its wider applications. In contrast to SMTJs, double barrier MTJ (DMTJ), where the voltage is divided over two single junctions, shows an improved bias dependence of TMR ratio. Recently, a TMR ratio of over 200% has been achieved in MgO-based DMTJs at room temperature (RT) by using CoFeB/CoFeB hybrid free layer. On the other hand, the spin-dependent resonant tunneling effect in DMTJs, which is reflected by an oscillation of the tunneling conductance, has attracted a lot of interest. The tunneling mechanism in DMTJs with such high TMR ratio becomes interesting.

II. EXPERIMENT AND THEORETICAL METHODS

DMTJ and SMTJ stacks were grown on thermally oxidized silicon wafers with layer sequences Ta 5/Ru 30/Ta 5/Ni81Fe19 5/Ir22Mn78 10/Co90Fe10 2.5/Ru 0.9/CoFeB 3/MgO 2.5/CoFeB 3/Ta 5/Ru 5 and Ta 5/Ru 30/Ta 5/Ni81Fe19 5/Ir22Mn78 10/Co90Fe10 2.5/Ru 0.9/CoFeB 3/MgO 2.5/CoFeB 3/Ta 5/Ru 5 (in nm). The MgO layer was rf-sputtered from a target facing argon ion milling and lift-off techniques. The samples were then annealed at annealing temperature (T_a) ranging from 250 to 375 °C in high vacuum for 1 h under an in-plane magnetic field of 0.8 T. The magnetotransport properties were performed in a Physical Properties Measurement System using a conventional four-point method. Dynamic conductance and IET spectra were measured at 30.79 Hz with an ac modulation voltage of 4 mV using a standard lock-in method. The details of IET spectra measurement can be found in our previous papers.

III. RESULTS AND DISCUSSIONS

Figure 1 shows the T_a dependences of the TMR ratios at RT for the DMTJs and SMTJ. The TMR ratios of DMTJs and SMTJ increase with increasing annealing temperature up to T_a = 375 °C. The maximum TMR ratio for the SMTJ reaches 297%, whereas the TMR ratio of the DMTJ with the CoFe free layer is only 160% at RT. This TMR ratio is considerably enhanced with the insertion of amorphous CoFeB between CoFe and the upper MgO layer, reaching 192% and 222% for T_a = 0.5 and 1 nm, respectively. The reason for the enhanced TMR ratio is that the amorphous CoFeB grown on polycrystalline CoFe in the free layer facilitates the growth of a higher quality upper MgO tunnel barrier, and the 2 nm thick CoFe absorbs the boron when the thin CoFeB is annealed to produce the crystallized free layer that is needed for high TMR. The TMR ratio for T_a = 0.5 nm is not as high as that for T_a = 1.0 nm, which could be due to...
incomplete coverage of the CoFe by the thin CoFeB, and the subsequently grown MgO has a poor texture.

Figure 2(a) shows the temperature dependences of TMR ratio and resistance for DMTJ with $t_{\text{CoFeB}} = 1.0$ nm. The TMR ratio increases with decreasing temperature and reaches 260% at 2 K. The resistance is almost independent of temperature for the parallel configuration but increases with decreasing temperature for the antiparallel configuration, which are commonly observed features of MgO SMTJs.2 Figure 2(b) shows the temperature dependence of Q factor, $Q = \text{TMR}_{\text{top}}/\text{TMR}_{\text{total}}$, where TMR$_{\text{bottom}}$ and TMR$_{\text{top}}$ are the resistance changes in the bottom and top tunnel barriers divided by the total resistance of the DMTJ. The Q factor decreases with decreasing temperature, which reflects that the TMR contribution of top MTJ gets smaller at lower temperature. This may be due to poor antiparallel alignment between the free and top pinned layers resulting from the complex changes with temperature of the exchange bias of the top pinned layer and the coercivity of the free layer.

Figure 3(a) shows the dynamic conductance of SMTJ and DMTJs with $t_{\text{CoFeB}} = 0.5$ and 1.0 nm for the parallel configuration. The dynamic conductance shows symmetric features as a function of the bias voltage for $t_{\text{CoFeB}} = 1$ nm but distinctly asymmetric features for $t_{\text{CoFeB}} = 0.5$ nm. The asymmetric bias dependence probably originates from a difference in quality between top and bottom MgO barriers.

In addition, some unambiguous features at low bias were observed in $dI/dV$ curve for DMTJs. These detailed features were not observed in the previous work in DMTJs with thin CoFeB layer, in which the TMR is very low compared to the present samples.17 The IET spectra also shows several peaks at low bias for the parallel state, as shown in Figs. 4(a), 4(b), and 4(c), which can be identified from the features in the $dI/dV$ curves. It is necessary to point out that the IET spectra was measured by a lock-in method, and not derived by numerical differentiation of the $dI/dV$ curves. To understand the origin of features in the $dI/dV$ curves and peaks in the IET spectra, we compared the results with those for a SMTJ. For the SMTJ, the bias axis is multiplied by 2, and thus it can be considered as a supposed DMTJ composed by two identical SMTJs without any interaction between them. In the $dI/dV$ curves, the features for DMTJs are quite similar to those of the scaled SMTJ. In the IET spectra, all the positions of peaks for DMTJs correspond well to those of the scaled SMTJ, labeled by dashed lines. In addition, there are double minima of the conductance in DMTJs at higher bias. In our previous work,18 the double minima have been observed both in sputtered and electron beam evaporation grown SMTJs, which are usually attributed
to the contribution of the $\Delta_3$ majority electron channel or $\Delta_1$ minority electron channel.\textsuperscript{12} Also, the double minima for DMTJs are quite similar to those of the scaled SMTJ. By comparing the $\text{d}I/\text{d}V$ curves and IET spectra of the DMTJ and the scaled SMTJ, it appears that the tunneling mechanism in DMTJ is similar to that of two SMTJs in series.

The origins of the peaks in the IET spectra can be explained as follows: the zero-bias anomaly appearing at 6 mV (3 mV for the SMTJ) may be caused by magnetic impurities or electron-electron interactions in presence of disorder in CoFeB electrodes.\textsuperscript{12,13} A wide shoulder-like peak is located at around 60 mV (30 mV for the SMTJ) may be due to magnon excitation.\textsuperscript{12-16} Another wider peak visible around 150 mV (75 mV for SMTJ) is usually considered as a signature of MgO-phonon excitation.\textsuperscript{12–15} Thus, compared with the scaled SMTJ, all the features in $\text{d}I/\text{d}V$ curve and peaks in IET spectra in DMTJs can be understood.

The dynamic conductance for the antiparallel configuration is shown in Fig. 3(b). No obvious features were observed as for the parallel state except the increase of conductance with bias. In the IET spectra for the antiparallel configuration, as shown in Figs. 4(d), 4(e), and 4(f), the positions of peaks for the scaled SMTJ and DMTJs are not coincident and the bias values of peak positions for DMTJs are smaller. It may be due to an ill-defined antiparallel state in the top MTJ, thus the bottom MTJ contributes more to the resistance and the IET spectra mainly reflects the bottom MTJ.

In our samples, no oscillation in conductance was observed at low temperature despite the high TMR. Possible reasons for the absence resonant tunneling in our DMTJs include the presence of boron in the free layer, relatively poor quality of top MgO compared to bottom MgO, and the absence of atomically flat surfaces over the entire junction area as pointed out by Herranz et al.\textsuperscript{8}

\begin{figure}[h]
\centering
\includegraphics[width=0.8\textwidth]{figure4.png}
\caption{IET spectra in the P [(a), (b) and (c)] and AP [(d), (e) and (f)] configurations at 2 K for the SMTJ and DMTJs.}
\end{figure}

\section*{IV. SUMMARY}

In conclusion, we have investigated the dynamic conductance and IET spectra in SMTJ and DMTJs with a CoFe/CoFeB free layer. The CoFeB insertion can considerably improve the TMR ratio of the DMTJ. By comparing the DMTJs with a scaled SMTJ, the features in the dynamic conductance and IET spectra of the DMTJ were identified; it is suggested that DMTJ can be considered as two SMTJs in series. Unfortunately, no resonant tunneling could be observed in our devices, despite their high TMR.

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